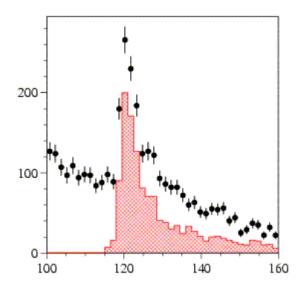
Review Tracking and Vertexing

Jan Timmermans - NIKHEF

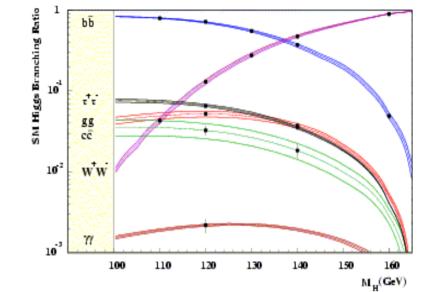
32 presentations in total:

- •12 vertex detector related
- •10 on SI tracking
- •10 on TPC R&D

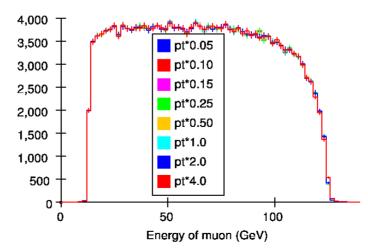
Physics



Inclusive Higgs: Z Recoil mass



H Branching Ratios



ILC500-SDMAR01-Smuon-SPS#1

Smuon pair-production

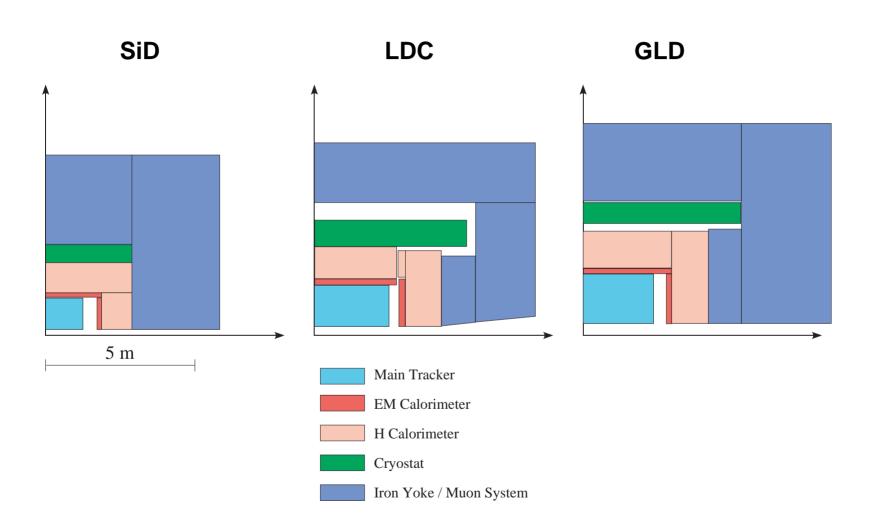
Basic design concept

• Performance goal (common to all det. concepts)

- Vertex Detector:
$$\delta(IP) \le 5 \oplus 10 / p \sin^{3/2} \theta$$

- Tracking: $\delta p_t / p_t^2 \le 5 \times 10^{-5}$
- Jet energy res.: $\delta E / E \le 0.3 / \sqrt{E}$

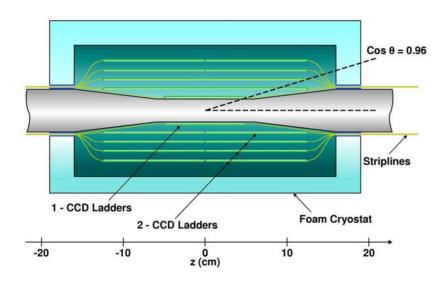
→ Detector optimized for Particle Flow Algorithm (PFA)



Comparison of parameters:

		SiD	LDC	GLD
Solenoid	B(T)	5	4	3
	R(m)	2.48	3.0	3.75
	L(m)	5.8	9.2	9.86
	E _{st} (GJ)	1.4	2.3	1.8
Main Tracker	R _{min} (m)	0.2	0.36	0.4
	R _{max} (m)	1.25	1.62	2.0
	σ(μ m)	7	150	150
	N _{sample}	5	200	220
	σ(1/pt)	3.6e-5	1.5e-4	1.2 e-4

Vertex Detector



- •pixels ~ 20 x 20 µm²
- •point resolution ~3 µm
- •material <0.1% X₀
- •1st layer at ~1.5 cm

To keep occupancy below 1%:

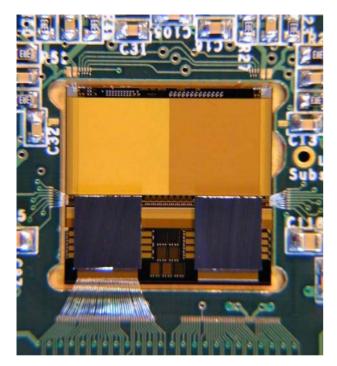
•readout ~20 times during bunch train or store signals •OR make pixels smaller (FPCCD 5 x 5 μ m²) Many variants: CPCCD, FPCCD, DEPFET, MAPS, FAPS, Sol, ISIS

New at LCWS05:

•(revolver)ISIS

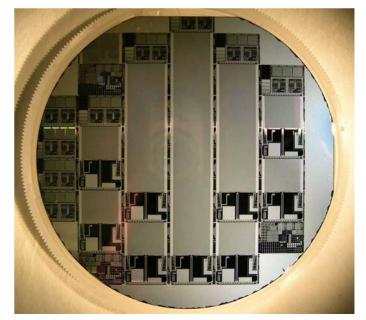
•Add time stamping (Baltay, Bashindzhagyan)

CPCCD, (revolver)ISIS (K. Stefanov - LCFI)

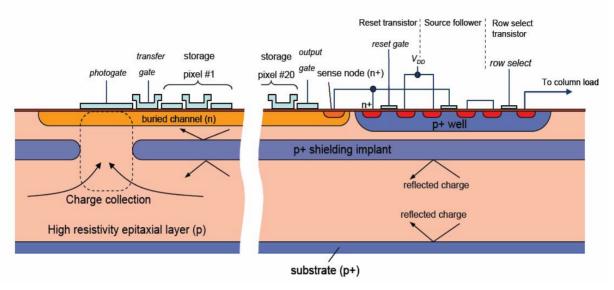


•CPC1: 750x400 pixels, 20x20 μm^2

- •Bump bonded by VTT to readout CPR1
- •Clocked at 25 MHz
- •Various sized (up to 92mmx15mm) CPC2 detector chips
- +ISIS chips in production



ISIS R&D



• RF pickup is a concern for all sensors converting charge into voltage during the bunch train;

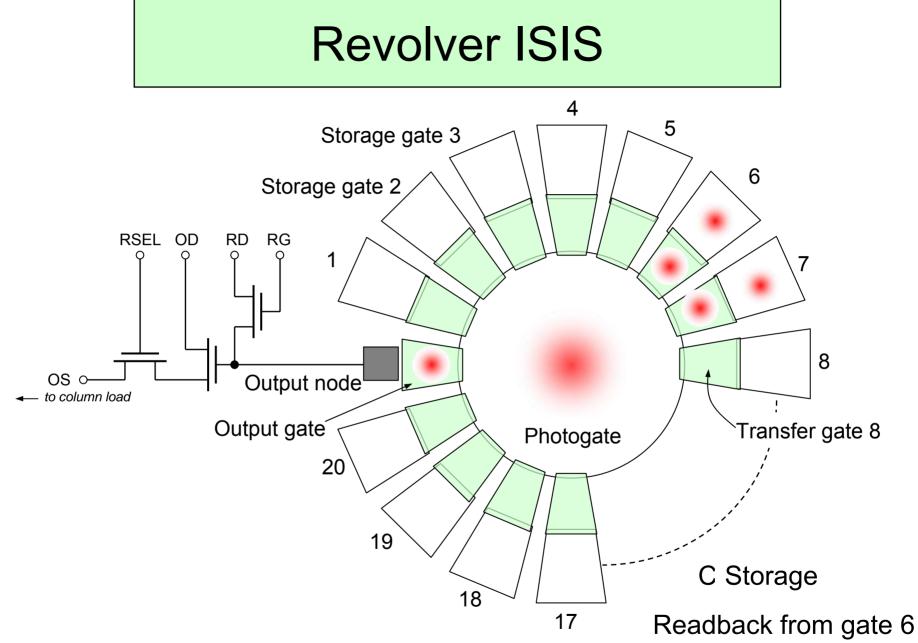
• The In-situ Storage Image Sensor (ISIS) eliminates this source of EMI:

Charge collected under a photogate;

Charge is transferred to 20-pixel storage CCD in situ, 20 times during the 1 ms-long train;

Conversion to voltage and readout in the 200 ms-long quiet period after the train, RF pickup is avoided;

* 1 MHz column-parallel readout is sufficient;



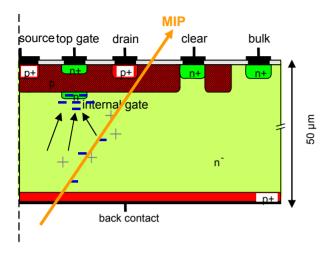
Vertex Detector Options

FPCCD

- Accumulate hit signals for one train and read out between trains
- Keep low pixel occupancy by increasing number of pixels by x20 with respect to "standard" pixel detector
- As a result, pixel size should be as small as $\text{~}5\text{x}5\mu\text{m}^2$
- Epitaxial layer has to be fully depleted to minimize charge spread by diffusion
- Operation at low temperature to keep dark current negligible (r.o. cycle=200ms)

Tracking efficiency under beam background is critical issue; simulation needed.

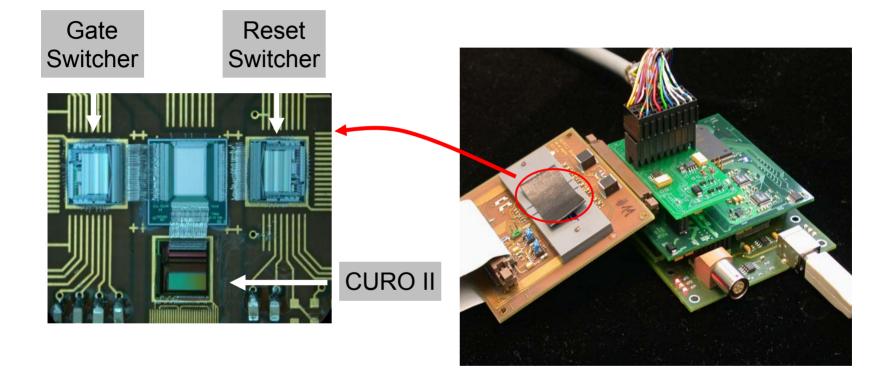
DEPFET (M. Trimpl) – Bonn, Mannheim, MPI



charge collection in fully depleted substrate

- small pixels 20-30µm
- radiation tolerance (>200krad)
- low noise
- thin devices (50 μ m) \rightarrow S/N = 40
- low power (row-wise operation)
- fast readout (cold machine), 50MHz line rate
- zero suppressed data
- •FET transistor in every pixel (first amplification)
- •Electrons collected at internal gate modulate the transistor current. Signal charge removed via CLEAR
- No charge transfer
- Low power consumption: ~5W for full VXD

ILC-DEPFET system

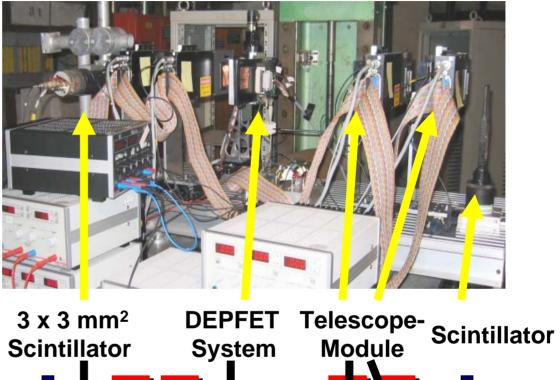


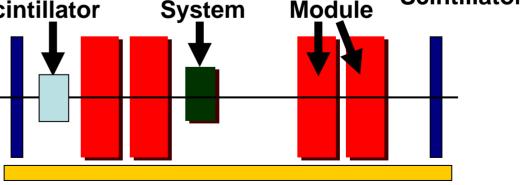
Testbeam: Setup

Testbeam 24 @ DESY

Jan + Feb 2005



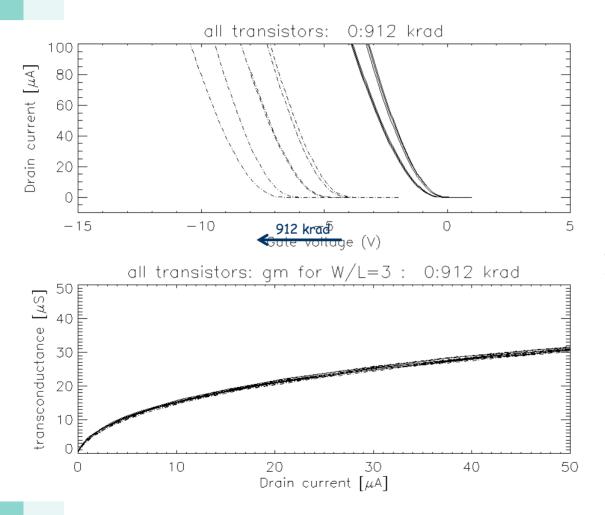






The Active DEPFET Pixel Sensor: Irradiation Effects due to Ionizing Radiation

L. Andricek

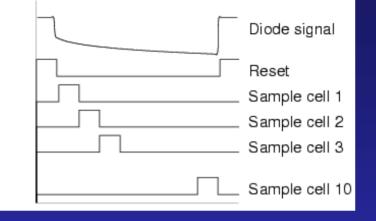


Irradiated with ⁶⁰Co gammas up to 912 krad

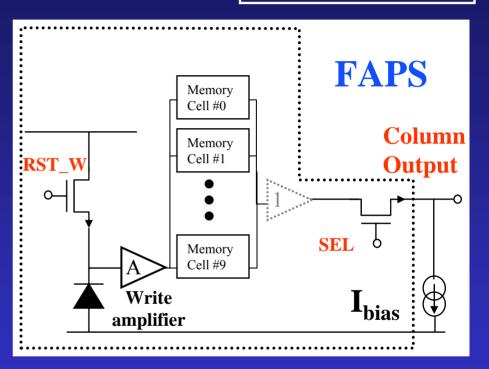
Acceptable small shift in threshold voltages (for 6 DEPFETs)

Flexible APS

J. Velthuis – UK MAPS



- FAPS=Flexible APS
 - Every pixel has 10 deep pipeline
- Designed for TESLA proposal.
 - Quick sampling during bunch train and readout in long period between bunch trains

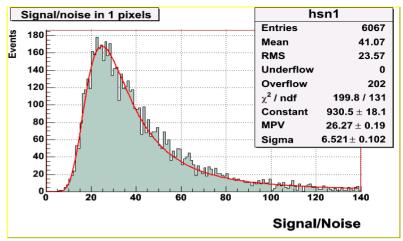


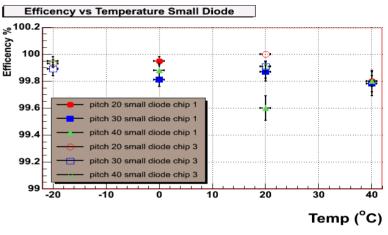
•S/N between 14.7 and 17.0

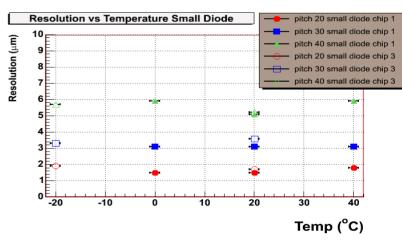
Performances Achieved with MIMOSA chips

- 11 MIMOSA prototypes designed and fabricated since 1999
- 6 fabrication processes explored: AMS-0.6μm, AMI-0.35μm, AMS-0.35μm (opto and ordinary), IBM-0.25μm, TSMC-0.25μm
- Most chips tested with ~10² GeV/c π⁻ (CERN-SPS)
 - − S/N ~ 20-30 (MPV) \Rightarrow $ε_{det}$ ~ 99-99.9 %
 - $\sigma_{sp} = 1.5-2.5 \ \mu m (20 \ \mu m pitch);$ $\sigma_{2hits} ≥ ~ 30 \ \mu m$
 - Rad. Tol. For ILC conditions checked with neutrons and X-Rays
 - Reticle size chip fabricated and working well (e.g. imager)
 - Assessment of 50 μm thinning under way
- Application to STAR, CBM, etc.

M. Winter - Strasbourg







Summary and Outlook

- Concept of vertex detector using features of CMOS sensors progressing, based on requirements accounting for uncertainties (e_{BS} !)
- Well established performances:
 - S/N, $\varepsilon_{det'} \sigma_{sp}$
 - Rad. Tolerance to neutrons and X-Rays
 - 120 μm thinning of Megapixel sensors
- Most recent achievements
 - Fast col. // pixel architecture (integrated CDS) found, with low noise (< 20 e⁻ ENC) and small pixel-to-pixel dispersion
 - Assessment of a well performing R&D fabrication process: AMS-035 μm (opto and epi-free) ⇒ very good perfo. even with 40 μm pitch (L4)
 - Checks of tolerance to 10-20 MeV electrons under way
 - Outcome of thinning to 50 μ m under study ($\geq \sim$ 15 μ m not yet OK)
- Next important steps:
 - 1) Fast column // sensor with digital output, adapted to L0-1 (integrated low power, fast and compact 4-bit ADC)
 - 2) New multi-memory cell sensor adapted to L2-4
 - Complete study of MIMOSA-5 thinning to \sim 50 μ m with LBL
 - Investigate characteristics of new fab. processes (e.g. IBM-0.13 μ m, UMC-0.18 μ m)
 - Thinning no-epi sensors is very appealing: any possibility ?
 - Privileged contact with a foundry would be very valuable...
- > Aim for a fast col. // megapixel proto providing digital output in 2007

D. Contarato - DES**Conclusions & Outlook**

Beam-test of CMOS sensors with 6 GeV electrons at DESY

- Results for signal, S/N and noise consistent with known values (from Strasbourg tests)
- No significant temperature effect observed between -15°C and +5°C
- Efficiency still under study

Irradiation with 10 MeV electrons

- Irradiation at doses comparable with expectations for first VXD layer background
- <u>Preliminary</u> results from ⁵⁵Fe calibration show loss in performance after 3×10¹² e/cm²: further investigations under way

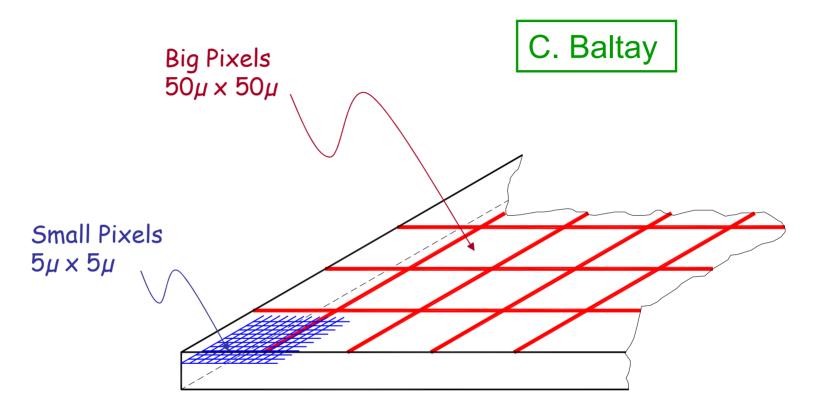
Next steps

- Efficiency check: priority!
- Improve telescope performance/alignment: eventual position resolution studies from energy scans
- Beam-test of irradiated chip





Monolithic CMOS Pixel Detectors



Two active particle sensitive layers:

After selecting hits in same bunch: occupancy ~10⁻⁶

Big Pixels - High Speed Array - Hit trigger, time of hit Small Pixels - High Resolution Array - Precise x,y position, intensity

Array Designs

High-speed arrays

- Designed for quick response.
 - Threshold detection only.
 - Large pixels (~50 x 50 μ m).
- Transmits X,Y location and time stamp of impact.

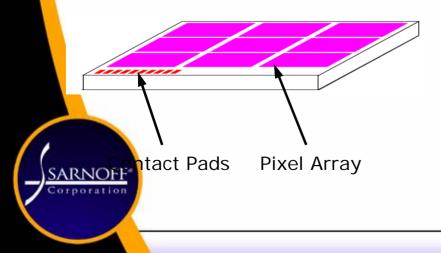
High-resolution arrays

- Designed for resolution and querying.
 - Smaller pixel size (~5 x 5 μ m).
 - Random access addressability.
 - Records intensity.

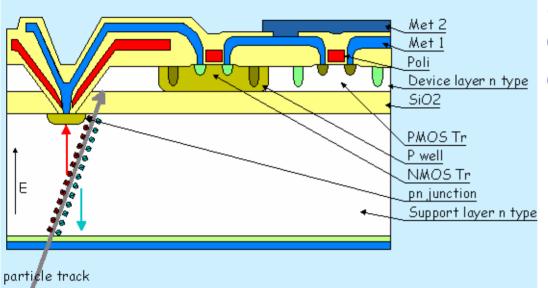
Contact Pads

 Provides intensity information only for pixel region queried.

Pixel Array

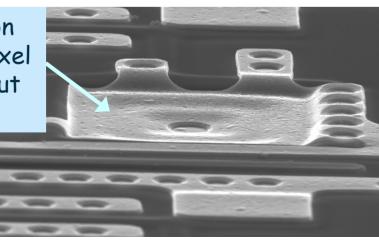


A. Bulgheroni - Como Principle of SOI monolithic detector



Connection between pixel and readout channel

AGH



Integration of the pixel detector and readout electronics in a waferbonded SOI substrate

Detector \rightarrow handle wafer

- High resistive
 (> 4 kΩcm,FZ)
- 400 μm thick
- Conventional p⁺-n

Electronics → active layer

- Low resistive
 (9-13 Ωcm, CZ)
- 1.5 μm thick
- Standard CMOS technology

First large-scale SOI Detectors

- Fully functional detectors with implemented readout blocks on chip
 - 128 x 128 readout channels
 - area 2.4 cm x 2.4 cm
 - 4 independent sub-matrices
 - Operation in charge integration mode
 - Dead time below 1% with respect to integration time

Optimised for medical applications





- "Baby Detector" 48 x 48 readout channels, area 1.2 cm x 1.2 cm, no digital control blocks
- Column, row and reset signals generated by Xilinx CPLD (XC95288XL)

Si Tracking

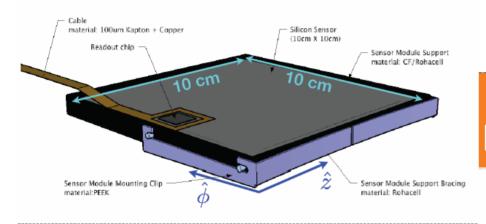
Alternative: Small Modules

- Shift responsibility for rigid/robust support onto underlying structure: Nested, closed carbon-fiber / Rohacell cylinders (a la D0 CFT, Atlas SCT)
- Tile cylinders with small, simple modules, each with own readout
 - 👃 Very high S/N (~20)
 - 👃 Simple, low-risk assembly
 - One hand" installation/handling: even in-situ replacement possible

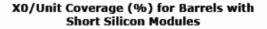
Bill Cooper (FNAL) 1262 554.4 3374.56 national: 100wm Kapton + Consert Silicon Sensor DOM: N DROMA Reading show Sonator Mindule Support reserval: CF/Robacell Sensor Medule Mounting Clip Sensor Module Separat Brazine MAN PARTY AND replaced Rehard

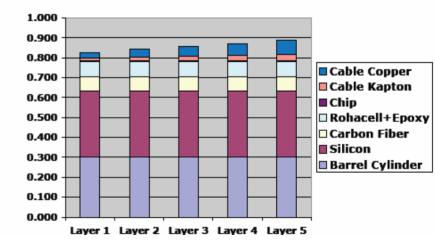
T.Nelson

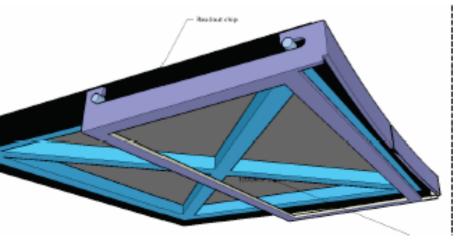
Short Module Design



Barrel Material

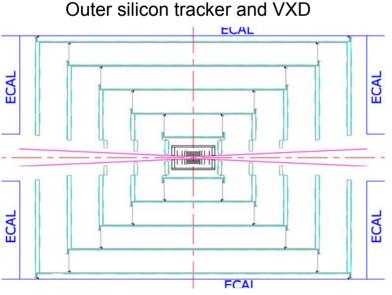




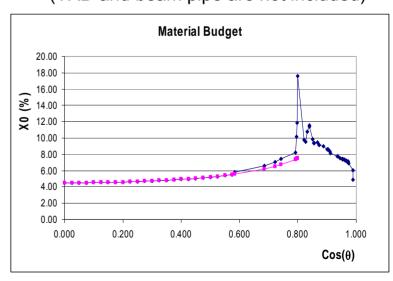


Design of the SiD Silicon Tracker

- Support of barrels and disks is based upon sandwiches of carbon fiber (epoxy) Rohacell – carbon fiber (epoxy).
- Barrel lengths vary with radius to allow disks to be inset.
 - Barrels of uniform lengths with disks at ends are also under consideration.
- The Victoria design assumed:
 - Single-sided sensors
 - No stereo in the barrels and approximately 90° stereo in the disks
 - Forced air cooling, which implies that readout chip power must be cycled.
- Simulation studies are in progress to understand the number of barrels and disks, and the number of stereo layers, needed.
 X0 (%) versus cos(A)



X0 (%) versus $cos(\theta)$ (VXD and beam pipe are not included)

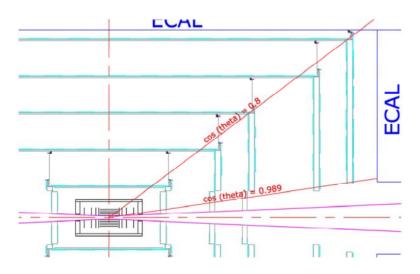


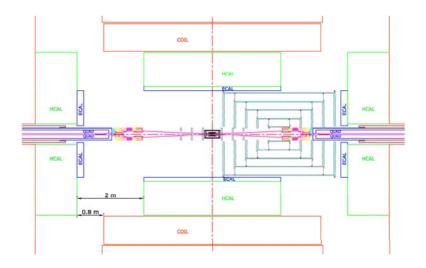
Modifications to the Design

- Barrel lengths can be varied to redistribute material in the X0 peak at $cos(\theta) \approx 0.82$.
- Possible designs of barrel sensor module support structures have been proposed.
- Work to integrate the outer silicon tracker and the VXD geometries has begun.
 - Provisions to service the VXD assume that the outer tracker is moved longitudinally while the VXD and beam line elements remain fixed.
 - Disks of the outer tracker have been separated into inner and outer portions to achieve that.
 Inner portions would be supported from the beam pipe.

Layout with barrel lengths adjusted to distribute X0 peak. Separated disk portions are shown, also.

Tracker opened for VXD servicing





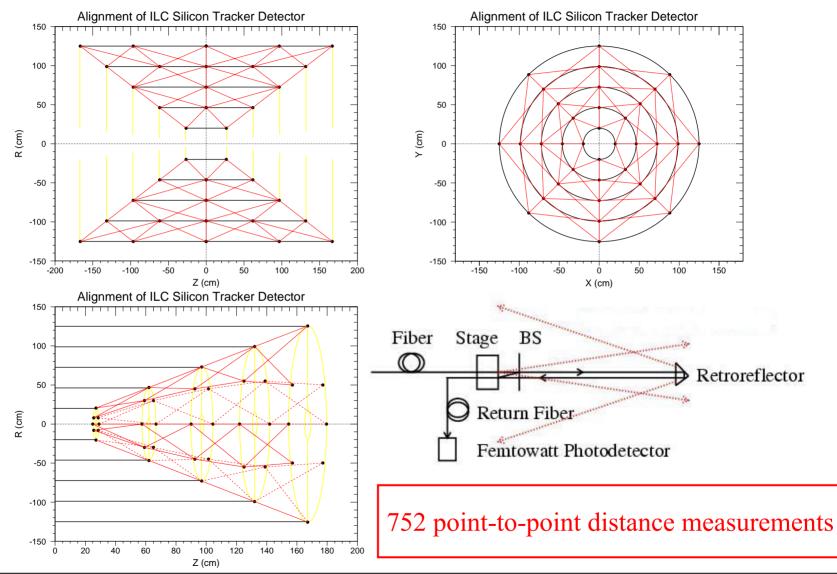
Frequency Scanned Interferometer for ILC Tracker Alignment

Hai-Jun Yang, Sven Nyberg, Keith Riles University of Michigan, Ann Arbor

8th International Linear Collider Workshop SLAC, March 18-22, 2005

A Possible SiD Tracker Alignment





Worldwide Study of the Physics and Detectors

for Future Linear e' e- Colliders



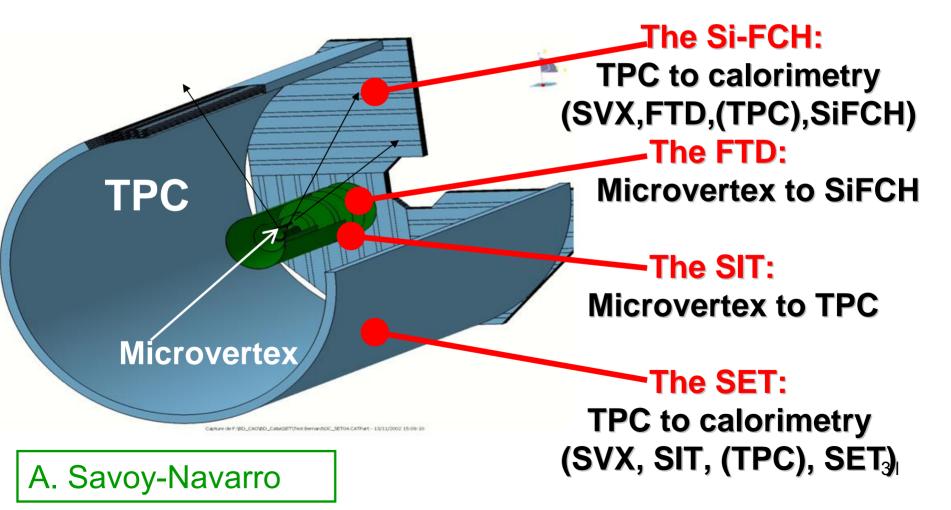


- ➔ Two FSI demonstration systems, with or without optical fibers, were constructed to make high-precision absolute distance measurements.
- ➔ Two new multi-distance-measurement analysis techniques were presented to improve absolute distance measurement and to extract the amplitude and frequency of vibration.
 - A high precision of ~50 nm for distances up to 60 cm under laboratory conditions was achieved.
- → Major error sources were estimated, and the expected error was in good agreement with spread in data.
- ➔ We are investigating dual-laser scanning technique used by Oxford ATLAS group currently.
- Michigan group has extended the frontier of FSI technology, but much work lies ahead.

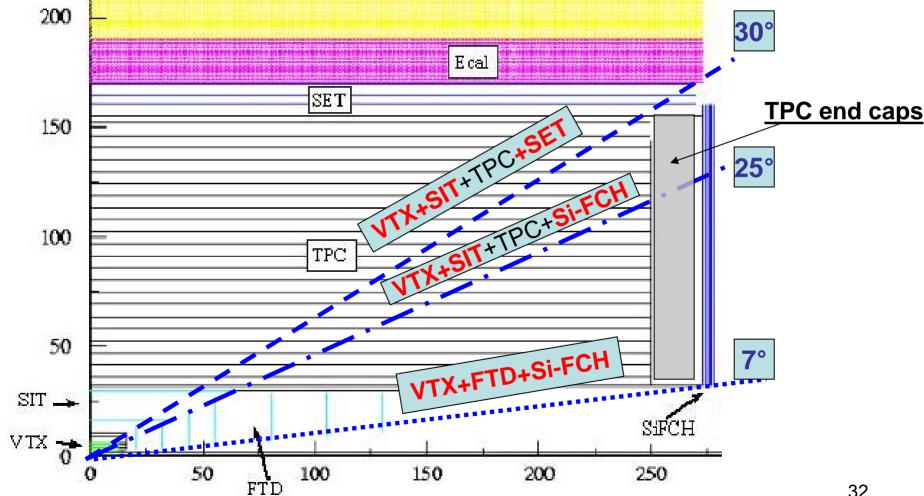
Silicon Tracking System with a central gaseous detector

The Silicon Envelope concept =

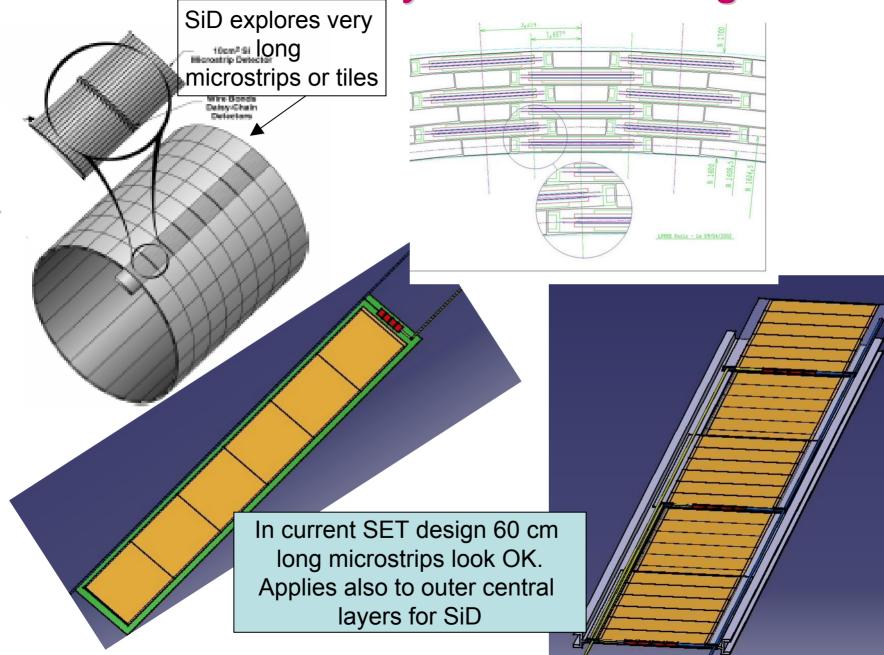
ensemble of Si-trackers surrounding the TPC (LC-DET-2003-013)



Crucial Keywords: ✓ Robustness ✓ Full coverage ✓Improved performances



Central Outer Si layers: current design



Prototype chip received February 28th

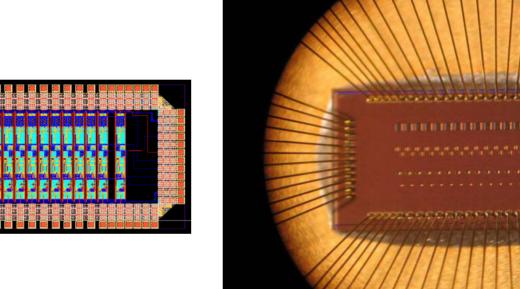


- Two blocks of 1.6 x 1.6 mm² each

J.-F. Genat

34 Jean-Francois Genat, LCWS05, Stanford, March 20th 2005

Silicon



THE REPORT OF THE PARTY OF THE

3mm

16 + 1 channel UMC 0.18 um chip (layout and picture)

35

Jean-Francois Genat, LCWS05, Stanford, March 20th 2005

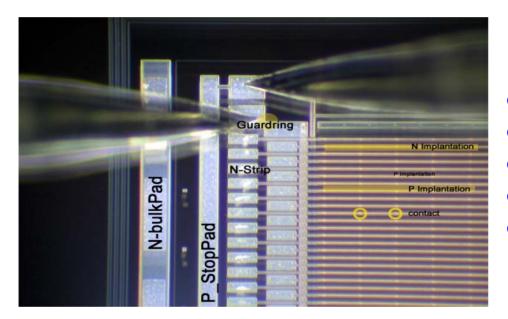
Just received ! Very first preliminary results

Two tested chips fully functional

Preamp + Shaper Under Preamp: Gain 8mV/MIP OK +/-1.5% Linearity Dynamic range: 75 MIP OK Noise @ 3.3pF input cap, 3 μ s shaping time: 205 e-140 e- expected Shaper: 2 - 10 μ s tunable peaking time OK Preamp **90 μW** 70 µW expected Power: Shaper **110 μW** 30 W full detector OK

Jean-Francois Genat, LCWS05, Stanford, March 20th 2005

Development of Double-sided Silicon Strip Detector



- Introduction
- Electrical Test
- Source Test
- Radiation Damage Test
- Summary and Future Plan

•Fabrication "in house"

•5" wafers

H. Park (BAERI, KNU) On behalf of Korean Silicon Group

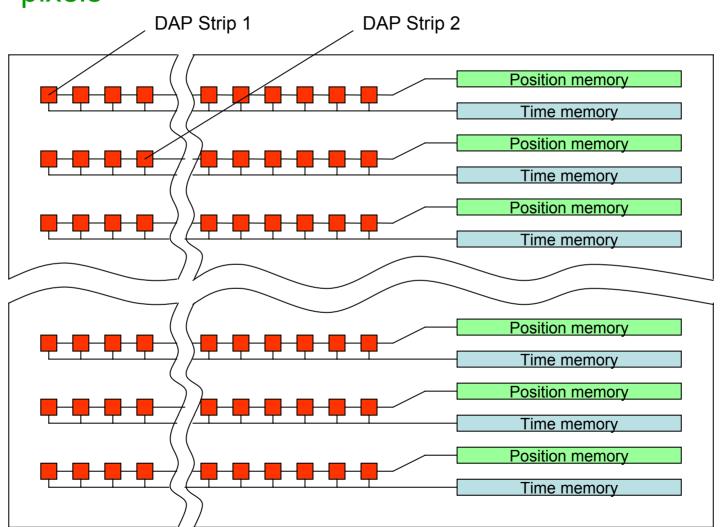


G.Bashindzhagyan N.Sinev LCWS 2005

G.Bashindzhagyan

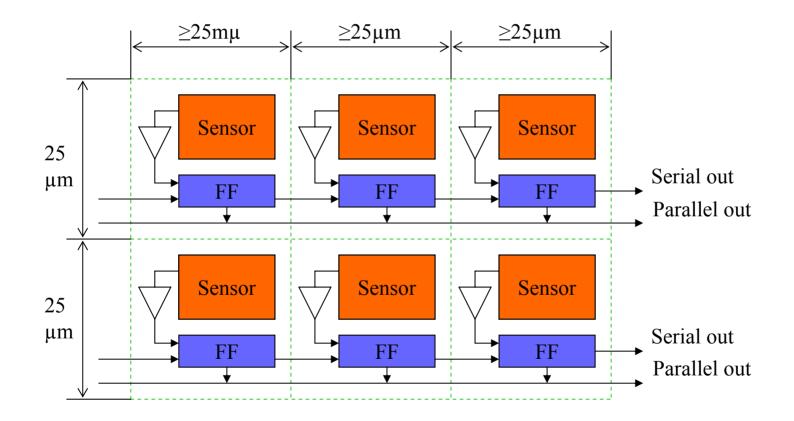
Digital Active Pixel Array

25x25 µm² pixels



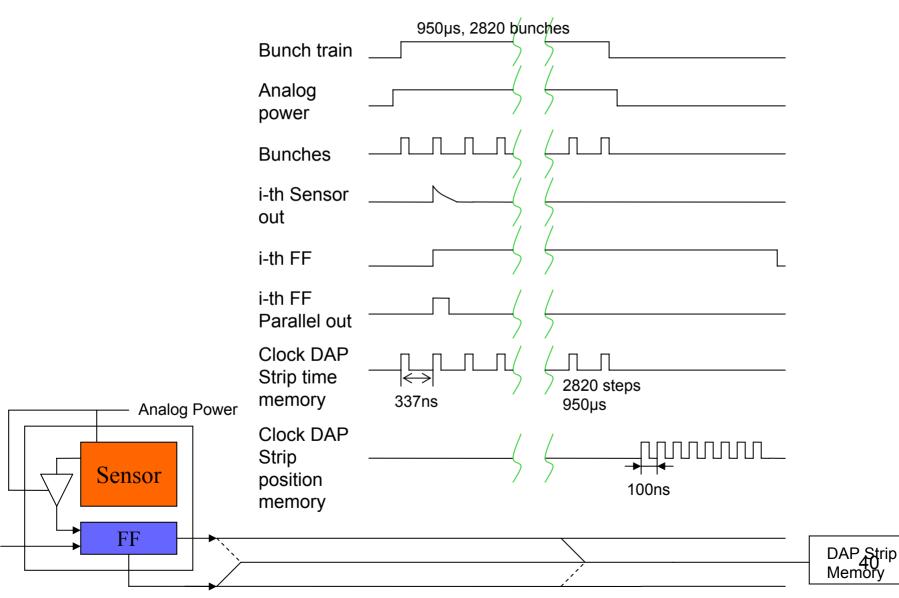
G.Bashindzhagyan N.Sinev LCWS 2005

Digital Active Pixel Array <u>Pixel Structure</u>



G.Bashindzhagyan N.Sinev LCWS 2005

Digital Active Pixel Array <u>Timing Diagram</u>



TPC R&D

•Gas amplification: GEM, Micromegas; compare with wires

•Different gases: Ar-CH4(5%)-CO2(2%) 'TDR'

Ar-CH4(5%,10%) P5, P10

Ar-iC4H10(5%)

Ar-CF4(2-10%)

He-iC4H10(20%)

CF4 Helium

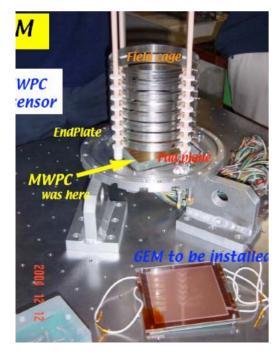
Isobutane

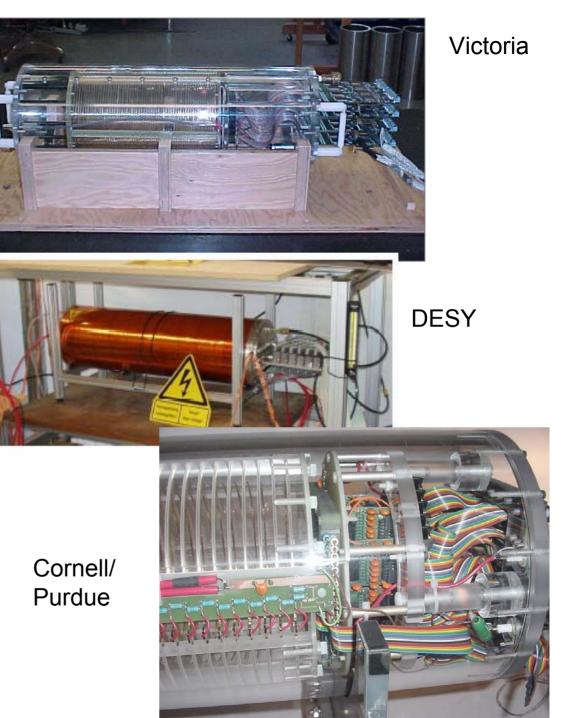
- •Laser studies
- •Field cage optimisation
- •Mapping a large parameter space



Aachen

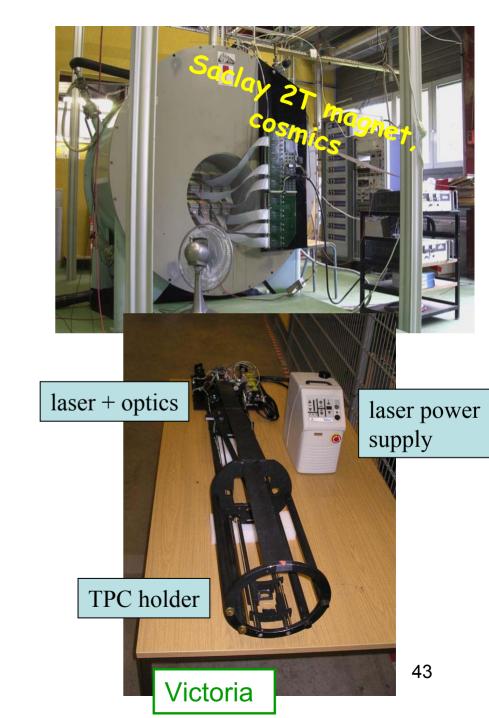
MPI/Asia











Many groups involved:

•Aachen, DESY, Hamburg U., Karlsruhe, Krakow, MPI-Munich, NIKHEF, BINP Novosibirsk, Orsay, Rostock U., Saclay, PNPI StPetersburg

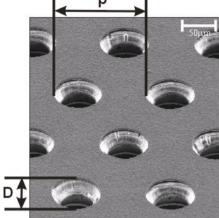
•Carleton, Berkeley, Montreal, Victoria

•Chicago/Purdue, Cornell, MIT, Temple/Wayne State, Yale

•Chiba U., Hiroshima, Minadamo, Kinki U., Osaka, Tokyo (4 groups), Tsukuba (2 groups)

Gas-Amplification Systems: Wires & MPGDs→

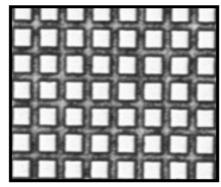
GEM: Two copper foils separated by kapton, multiplication takes place in holes, uses 2 or 3 stages

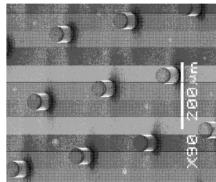


P~140 µm

D~60 µm

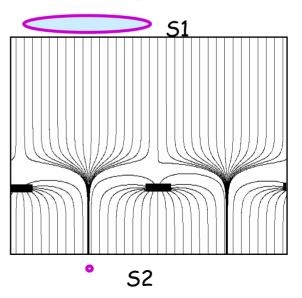
Systems: Wires & MPGDs→ Micromegas: micromesh sustained by 50µm pillars, multiplication between anode and mesh, one stage

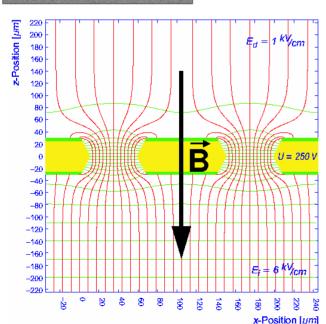




45

S1/S2 ~ Eamplif / Edrift





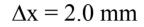
Double track fits: 2mm wide pads

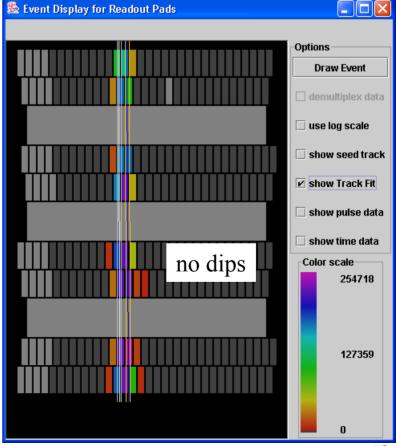
 $\sigma = 0.5 \text{ mm}$

繼 Event Display for Readout Pads	
Pad # 58	
	Options
	Draw Event
	🗌 demultiplex data
	🗌 use log scale
	show seed track
	✓ show Track Fit
	🗌 show pulse data
dips between	show time data
tracks	Color scale
	248874
	124437
	0

 $\Lambda x = 3.8 \text{ mm}$

D. Karlen

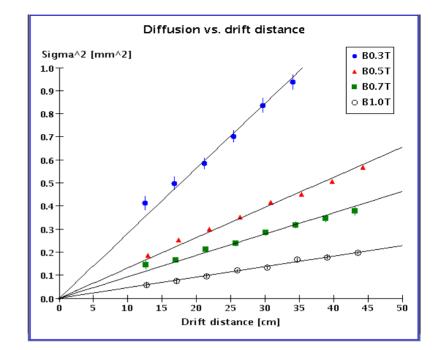




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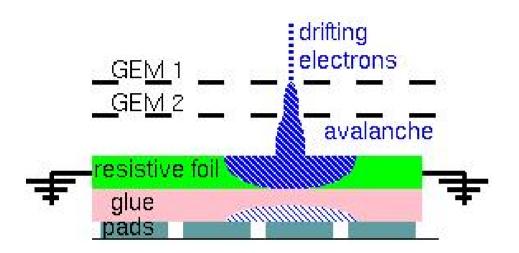
Micromegas:Diameter 50 cm





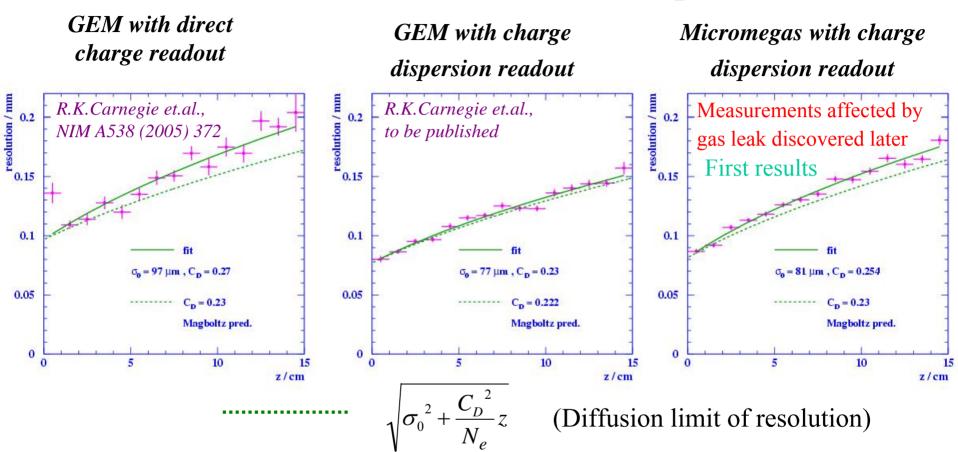
Charge spreading through resistive foil; can still use 'wider' pads – Carleton + Orsay + Saclay

M. Dixit



 $2 \times 6 \text{ mm}^2 \text{ pads}$

TPC transverse resolution for Ar:CO₂ (90:10)



Compared to direct charge readout, charge dispersion gives better resolution for GEM with Z dependence close to the diffusion limit. For Micromegas, the resolution, even with electron loss, is better than for direct charge GEM readout.

Resolution measurements (best results obtained):

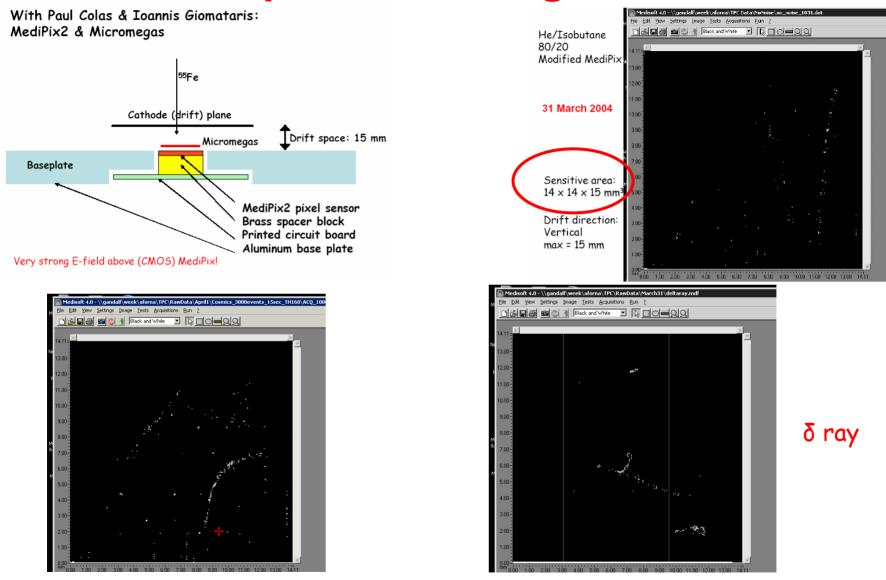
- 90-110 μm for 2x7 $mm^2\,pads,~P5$ gas ~at~4T
- •70-80 μm for 1.2x7 mm^2 pads, P5 gas, 4T
- •~100 μ m for 2x6 mm² pads, P10 gas, 1T

•77 µm at short drift distance for 2x6 mm² pads, B=0, Ar-CO2 (90%-10%); at 4T ~100 µm up to 2.5 m drift appears within reach.

•Transverse diffusion seems smaller than with Magboltz calculation

•Laser study: 2-track separation (transv.) of ~2mm; (longit.) <1 cm

Results pixel readout gas detectors

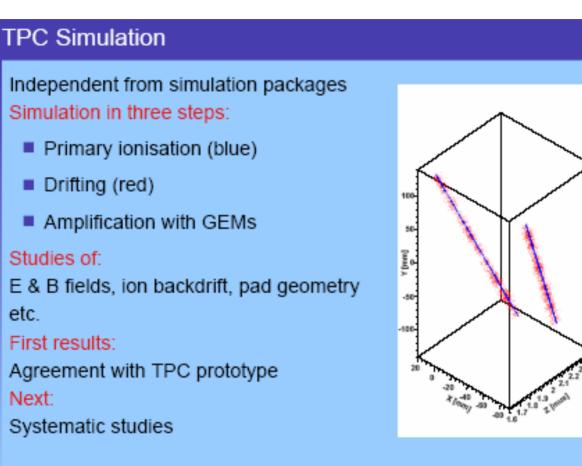


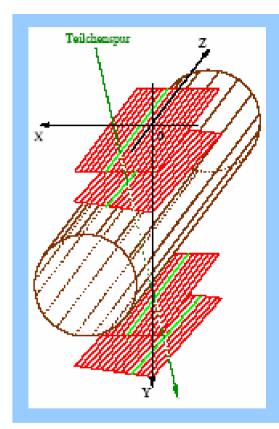
Observation of min. ionising cosmic muons: high spatial resolution +

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individual cluster counting !

A. Muennich - Aachen





Hodoscope Si modules, 122 µm pitch

Also detailed simulation in Victoria (D. Karlen)

Some physics resolution studies:

•S. Hillert (Oxford) – heavy flavour ID and quark charge measurement

•H. Yang (Michigan) – Higgs and slepton properties

•B. Schumm (Santa Cruz) – SUSY constraints on fw tracking

Many activities, new devices, new results.

For sure a lot more at next meeting.

Apologies for omissions, my mis-understandings, wrong presentations, etc....